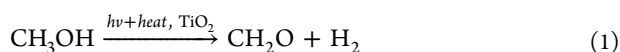


Molecular Hydrogen Formation from Photocatalysis of Methanol on TiO<sub>2</sub>(110)Chenbiao Xu,<sup>†,‡,§</sup> Wenshao Yang,<sup>†,§</sup> Qing Guo,<sup>\*,†</sup> Dongxu Dai,<sup>†</sup> Maodu Chen,<sup>‡</sup> and Xueming Yang<sup>\*,†</sup><sup>†</sup>State Key Laboratory of Molecular Reaction Dynamics, Dalian Institute of Chemical Physics, 457 Zhongshan Road, Dalian 116023, Liaoning, P. R. China<sup>‡</sup>School of Physics and Optoelectronic Engineering, Dalian University of Technology, 2 Linggong Road, Dalian 116024, China

## S Supporting Information

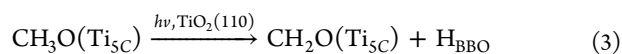
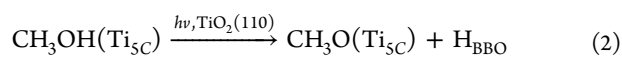
**ABSTRACT:** It is well established that adding methanol to water could significantly enhance H<sub>2</sub> production by TiO<sub>2</sub>. Recently, we have found that methanol can be photocatalytically dissociated on TiO<sub>2</sub>(110) at 400 nm via a stepwise mechanism. However, how molecular hydrogen can be formed from the photocatalyzed methanol/TiO<sub>2</sub>(110) surface is still not clear. In this work, we have investigated deuterium formation from photocatalysis of the fully deuterated methanol (CD<sub>3</sub>OD) on TiO<sub>2</sub>(110) at 400 nm using a temperature programmed desorption (TPD) technique. Photocatalytic dissociation products formaldehyde (CD<sub>2</sub>O) and D-atoms on BBO sites (via D<sub>2</sub>O TPD product) have been detected. In addition to D<sub>2</sub>O formation by heating the photocatalyzed methanol/TiO<sub>2</sub>(110) surface, we have also observed D<sub>2</sub> product formation. D<sub>2</sub> is clearly formed via thermal recombination of the D-atoms on the BBO sites from photocatalysis of methanol. Experimental results indicate that D<sub>2</sub>O formation is more important than D<sub>2</sub> formation and that D<sub>2</sub> formation is clearly affected by the D<sub>2</sub>O formation process.

TiO<sub>2</sub> has attracted enormous interest in heterogeneous catalysis, photocatalysis, solar energy devices, etc.<sup>1–8</sup> Photocatalytic water splitting by TiO<sub>2</sub> is especially attractive because of its potential application in clean hydrogen production.<sup>9</sup> A previous study found that pure TiO<sub>2</sub> is not active for hydrogen production from pure water.<sup>10</sup> Adding methanol to pure water, however, can dramatically enhance hydrogen production.<sup>11</sup> Because of the apparently crucial role in hydrogen production, the photochemistry of methanol has been extensively investigated on single crystal TiO<sub>2</sub> surfaces<sup>12–31</sup> and TiO<sub>2</sub> powders.<sup>32–35</sup> Although investigations on powder TiO<sub>2</sub> with methanol steam<sup>32–35</sup> and a water–methanol mixture<sup>11</sup> show that hydrogen can be produced from methanol by reaction,



the detailed mechanism of gaseous hydrogen formation from methanol photocatalysis on TiO<sub>2</sub> remains unknown. In a recent study,<sup>28</sup> we have shown that the elementary photocatalytic dissociation of CH<sub>3</sub>OH on TiO<sub>2</sub>(110) without any other coadsorbed species occurs in a stepwise mechanism in which the O–H dissociation proceeds first and is then followed by

C–H dissociation to form formaldehyde (CH<sub>2</sub>O) with only methanol adsorption on TiO<sub>2</sub>(110),



where Ti<sub>5C</sub> refers to a five-coordinated Ti<sup>4+</sup>(Ti<sub>5C</sub>) site, and H<sub>BBO</sub> refers to an H atom adsorbed on a bridge-bonded oxygen (BBO) site on the TiO<sub>2</sub>(110) surface. From our experiment, we have found that both dissociation steps are photoinitiated. This means that at low temperature photocatalytic dissociation products from CH<sub>3</sub>OH, i.e., CH<sub>2</sub>O and H atoms on BBO sites, are all left on the TiO<sub>2</sub> surface after laser irradiation, whereas Henderson and co-workers found that molecular CH<sub>3</sub>OH is not photoactive on TiO<sub>2</sub>(110) using a Hg lamp as the surface photocatalysis source.<sup>26</sup> In our experiment,<sup>28,36</sup> we used a femtosecond laser source that has considerably higher photon flux than the Hg lamp used in ref 26, in addition to the highly sensitive mass spectrometric detector with a vacuum background of 1 × 10<sup>–12</sup> Torr. We believe this makes our experiment much more sensitive in detecting TPD products. Further oxidation of CH<sub>3</sub>OH on TiO<sub>2</sub>(110) to form methyl formate has also been observed in three different laboratories.<sup>36–38</sup> However, the important question of how hydrogen molecules are formed from the photocatalysis of methanol on TiO<sub>2</sub>(110) remains unanswered.

In order to understand the mechanism of hydrogen formation, the photocatalytic chemistry of CD<sub>3</sub>OD has been investigated on the TiO<sub>2</sub>(110) surface using temperature programmed desorption (TPD), in combination with laser surface photocatalysis. The surface photocatalysis-TPD apparatus used in this work has been described previously in detail.<sup>28,39</sup> The base pressure of the sample chamber of this apparatus is less than 6 × 10<sup>–11</sup> Torr. A highly sensitive quadrupole mass spectrometer (Extrel) is used to detect TPD products. To achieve the highest detection sensitivity and the lowest background, an extremely high vacuum of 1.5 × 10<sup>–12</sup> Torr was achieved and maintained in the electron-impact ionization region during the experiments for sensitive product detection. The TiO<sub>2</sub>(110) surface was cleaned by cycles of Ar<sup>+</sup> sputtering and resistive heating to 850 K in a vacuum until all impurities were removed. The TiO<sub>2</sub>(110) surface contained 3–

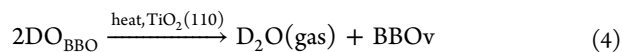
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4% O-vacancy defects as determined by H<sub>2</sub>O TPD.<sup>40</sup> CD<sub>3</sub>OD (Aldrich, 99+%) was purified by several freeze–pump–thaw cycles and was introduced onto the TiO<sub>2</sub>(110) surface with an accurately calibrated molecular beam doser. The surface temperature was maintained at 120 K during CD<sub>3</sub>OD sample dosing, and it typically rose to ~180 K during laser irradiation. The 400 nm irradiating light came from a frequency doubled Ti:Sapphire femtosecond laser (repetition rate 1 kHz). The average intensity of the laser beam on the sample was 400 mW with a diameter of 6 mm, corresponding to a flux of  $\sim 1.44 \times 10^{18}$  photons cm<sup>-2</sup> s<sup>-1</sup>. The light was incident on the TiO<sub>2</sub>(110) at  $\sim 30^\circ$  with respect to the TiO<sub>2</sub>(110) surface. TPD spectra after laser irradiation were measured using a heating rate of 2 K/s, with the surface normal directly pointing to the mass spectrometer.

The first experiment we carried out in this work was the investigation of the photocatalytic dissociation of CD<sub>3</sub>OD by measuring the TPD spectra of the CD<sub>3</sub>OD reactant (Figure S1A) and CD<sub>2</sub>O product (Figure S1B) as a function of 400 nm laser irradiation time. The TPD spectra at  $m/z = 36$  (CD<sub>3</sub>OD<sup>+</sup>) and  $m/z = 32$  (CD<sub>2</sub>O<sup>+</sup>) show that CD<sub>3</sub>OD becomes photocatalytically dissociated, while CD<sub>2</sub>O is formed. This result is analogous to our earlier observations involving CD<sub>3</sub>OH<sup>28</sup> and CH<sub>3</sub>OH<sup>36</sup> on TiO<sub>2</sub>(110). In order to detect

D-atoms on the BBO rows from the photocatalytic dissociation of CD<sub>3</sub>OD on TiO<sub>2</sub>(110), TPD spectra (Figure 1A) at  $m/z = 20$  (D<sub>2</sub>O<sup>+</sup>) have been measured, after different irradiation durations following adsorption of 0.5 ML of CD<sub>3</sub>OD on TiO<sub>2</sub>(110). Two main features are observed in the TPD spectra. The peak (marked with \*) slightly below 300 K is attributed to the dissociative ionization signal of molecular adsorbed CD<sub>3</sub>OD in the electron-impact ionizer and to a small impurity of D<sub>2</sub>O in CD<sub>3</sub>OD, which makes this peak

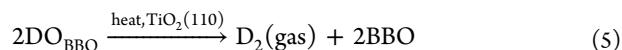
temperature lower than that of the molecularly desorbed CD<sub>3</sub>OD TPD peak. With no UV irradiation, a TPD peak at about 520 K is also observed, and it is the result of the recombination desorption of D<sub>2</sub>O made from two OD groups on BBO rows that produce water and leave behind an oxygen vacancy (see Figure 3):<sup>28</sup>



These D atoms are mainly produced by spontaneous dissociation of CD<sub>3</sub>OD at the BBO vacancy (BBOv) sites.<sup>41</sup> As laser irradiation time increases, the D<sub>2</sub>O peak from hydroxyl recombination increases in magnitude and the peak gradually shifts to lower temperatures. This shift is related to the increasing D-atom density on BBO sites from the photocatalytic dissociation of CD<sub>3</sub>OD adsorbed on the Ti<sub>5C</sub> sites. It is interesting to point out that oxygen vacancy will be created on the surface after recombination desorption of D<sub>2</sub>O from hydroxyl groups on BBO rows.<sup>28,29</sup>

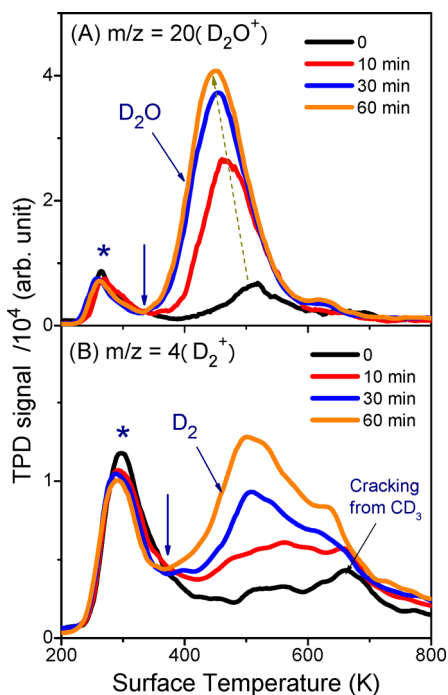
In order to determine if the molecular D<sub>2</sub> product could be formed, TPD spectra at  $m/z = 4$  (D<sub>2</sub><sup>+</sup>) were measured after 400 nm laser irradiation. Figure 1B shows TPD spectra for four different laser irradiation periods, corresponding to four different  $m/z = 4$  (D<sub>2</sub><sup>+</sup>) sources. The TPD peak (marked with \*) in the spectra slightly below 300 K comes from ionizer fragmentation of CD<sub>3</sub>OD (see Figure S2). The D<sub>2</sub><sup>+</sup> signal from this source decreases slightly as the laser irradiation time increases because of the depletion of CD<sub>3</sub>OD on the surface. In addition, D<sub>2</sub>O could also crack to produce D<sub>2</sub><sup>+</sup> in the ionizer. However, this D<sub>2</sub><sup>+</sup> source is negligible (see Figure S3). The third source of the D<sub>2</sub><sup>+</sup> ion is from the thermally desorbed CD<sub>3</sub> product from dissociatively adsorbed CD<sub>3</sub>OD on BBOv sites. This signal appears as a shoulder at ~630 K in the spectra and should not be dependent on the laser irradiation time.

In addition to the two considerable D<sub>2</sub><sup>+</sup> sources, another obvious source is the thermally desorbed D<sub>2</sub> product formed via recombinative desorption of D atoms on the BBO rows. As indicated in Figure 1B, the TPD peak near 500 K is most likely due to this source. This peak is ~50 K higher than the recombined D<sub>2</sub>O TPD peak and is also strongly dependent on the laser irradiation duration. When the surface temperature is above 450 K, molecularly adsorbed methanol and formaldehyde product on Ti<sub>5C</sub> have been already desorbed, and only hydrogen atoms on BBO rows and dissociatively adsorbed methanol on BBOv are still present on the surface.<sup>28</sup> Therefore, we can conclude that the 500 K TPD desorption peak at  $m/z = 4$  arises from D<sub>2</sub> formation from recombination of D atoms on BBO rows (see Figure 3):



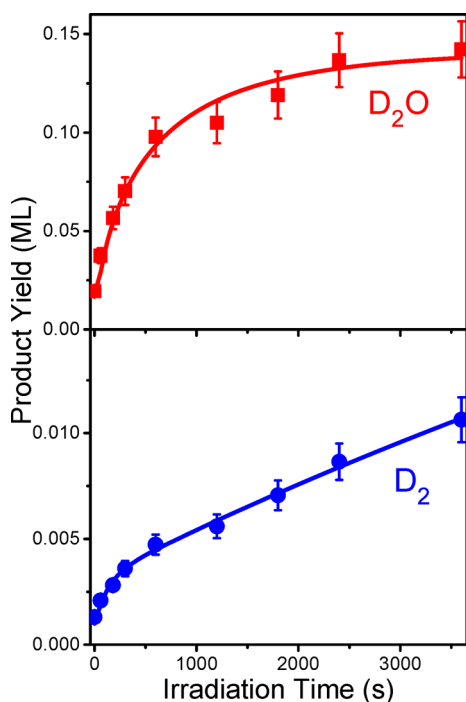
We have attempted to detect photodesorbed products at  $m/z = 4$  during irradiation, and no signals were detected, suggesting that D<sub>2</sub> product formation is not photodriven. From the above results and previous studies, we thus propose that molecular hydrogen formation from methanol photocatalysis on TiO<sub>2</sub>(110) has been the result of three elementary steps: stepwise photocatalytic dissociation of methanol (two steps) and thermal recombination of H atoms on BBO sites. We therefore conclude that hydrogen formation is a process whose rate-determining step is thermally activated recombination, as opposed to an electron- or hole-induced reaction.

In order to evaluate the relative importance of D<sub>2</sub> formation compared to D<sub>2</sub>O formation, the yields of D<sub>2</sub>O and D<sub>2</sub> as a



**Figure 1.** (A) Typical TPD spectra collected at  $m/z = 20$  (D<sub>2</sub>O<sup>+</sup>) following different laser irradiation times at 400 nm. (B) Typical TPD spectra collected at  $m/z = 4$  (D<sub>2</sub><sup>+</sup>) following different laser irradiation times at 400 nm.

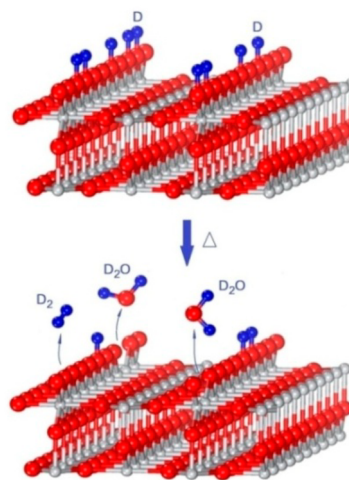
function of laser irradiation time have been measured (see Figure 2). The absolute yields of  $D_2O$  and  $D_2$  products shown



**Figure 2.** TPD product yield for  $D_2O$  and  $D_2$  as a function of irradiation time, derived from data in Figure 1.

in Figure 2 have been already calibrated based on the detection efficiencies of the two products in the quadrupole mass spectrometer detector. The calibrated result indicates that  $D_2$  formation is clearly less important than  $D_2O$  formation. This is consistent with the observation that the desorption of  $D_2$  starts from  $\sim 375$  K, which is  $\sim 50$  K higher than that of  $D_2O$ . The comparison of TPD temperatures suggests that  $D_2$  formation on  $TiO_2(110)$  is more difficult than  $D_2O$  formation. This result is fortuitously consistent with previous theoretical calculations, which show that the barrier for  $H_2$  recombinative desorption from BBO sites on  $TiO_2(110)$  is  $\sim 1.6$  eV, which is considerably higher than the barrier (1.10 eV) for  $H_2O$  desorption from BBO sites.<sup>42</sup> In ref 42, no  $H_2$  product was detected from the highly hydroxylated  $TiO_2(110)$  surface and was attributed to this high energy barrier. From these results, they reached a conclusion that hydrogen recombination is not possible on  $TiO_2(110)$ , whereas our result clearly indicates that hydrogen recombination on  $TiO_2(110)$  can happen. In addition, the observed 50 K difference only in the appearance temperature and the peak temperature between  $D_2$  and  $D_2O$  in this work implies that a calculated  $D_2$  recombination barrier of 1.6 eV might be a little too high relative to the  $D_2O$  desorption.

In comparison with molecular hydrogen formation from recombination of hydrogen atoms on  $TiO_2(110)$  (Figure 3), molecular hydrogen formation on H-atom covered  $Ru(0001)$ ,<sup>43</sup>  $Ru(001)$ ,<sup>44</sup>  $Pt(111)$ ,<sup>45</sup> and  $Al(111)$ <sup>46</sup> is much easier and occurs in a temperature range of 250–400 K, which is more than 100 K lower than the temperature for  $H_2$  formation on  $TiO_2(110)$ . Previous studies<sup>11,33</sup> have demonstrated that noble-metal-modified  $TiO_2$  can indeed enhance the efficiency of hydrogen production with a methanol–water mixture considerably. This implies that hydrogen migrations from  $TiO_2$  to a noble metal surface could facilitate hydrogen production. These earlier



**Figure 3.** Mechanism of molecular water and molecular hydrogen (deuterium) production from hydrogen atoms on  $TiO_2(110)$  surface.

results in combination with our new TPD experiments show that molecular hydrogen formation via recombination of H-atoms is probably the rate-determining step in the photocatalytic hydrogen production from methanol on  $TiO_2$ .

From Figure 2, the rate of  $D_2O$  product formation as a function of laser irradiation time is quite different from that of  $D_2$  product. The  $D_2O$  yield increases very fast at first and then reaches a plateau, and this yield is anticorrelated well with the depletion of  $CD_3OD$ . Since one oxygen defect is created for one  $D_2O$  molecule formed during TPD, it appears that BBO defects make  $D_2O$  formation more difficult. The  $D_2$  yield, however, increases faster than that of  $D_2O$  as the number of BBO defects increases. Hence, more BBO defects created by  $H_2O$  recombinative desorption on the surface can make formation of  $D_2$  easier than  $D_2O$  formation.

In summary, our experimental investigation provides strong evidence that molecular hydrogen can be produced via a thermal recombination reaction of hydrogen atoms on BBO rows, produced by methanol photocatalysis on rutile  $TiO_2(110)$  with 400 nm irradiation, elucidating a possible and universal mechanism for  $H_2$  production with  $TiO_2$ -based catalysts. From our experimental results, it clearly shows that water formation from hydroxyl pairs on BBO rows has a lower barrier than molecular hydrogen formation. From the results of this work, we can conclude that lowering the barrier for hydrogen atom recombination is a key point to enhancing hydrogen production and suppressing water formation. Furthermore, adding water to the methanol sample may also help the hydrogen production process by impeding reaction 4 and maintain more H (or D) atoms on the BBO rows.

## ■ ASSOCIATED CONTENT

### ● Supporting Information

TPD data for  $CD_3OD$ ,  $CD_2O$ , and  $D_2O$  (Figures S1–S3). This material is available free of charge via the Internet at <http://pubs.acs.org>.

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### Author Contributions

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## Notes

The authors declare no competing financial interest.

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